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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/546,936	04/11/2000	Jui-Ping Li	1056-52	4254
. 75	90 01/30/2002			
Laff Whitesel & Saret LTD			EXAMINER	
Attorneys at La 401 N Michigar	n Avenue		MOORE, K	KARLA A
Chicago, IL 60611			ART UNIT	PAPER NUMBER
			. 1763	2
			DATE MAILED: 01/30/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

		(W)				
	Application No.	Applicant(s)				
Office Action Summary	09/546,936	LI ET AL.				
inos Modell Guillinary	Examiner	Art Unit				
The MAII ING DATE of this communication and	Karla Moore	1763				
The MAILING DATE of this communication app Period for Reply	lears on the cover sheet with the	e correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period we Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	36(a). In no event, however, may a reply be within the statutory minimum of thirty (30) will apply and will expire SIX (6) MONTHS from the application to be seen a NAME (Course the application to be seen as NAME).	timely filed days will be considered timely. om the mailing date of this communication.				
1) Responsive to communication(s) filed on						
	s action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4)⊠ Claim(s) <u>1-23</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-22</u> is/are rejected.						
7)⊠ Claim(s) <u>23</u> is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examiner.						
10)⊠ The drawing(s) filed on <u>11 April 2000</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.						
Applicant may not request that any objection to the						
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☑ None of:						
 Certified copies of the priority documents I 	have been received.					
Certified copies of the priority documents in	have been received in Applicat	ion No				
 3. Copies of the certified copies of the priority application from the International Bure * See the attached detailed Office action for a list of 	au (PCT Rule 17.2(a)).	_				
	14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).					
a) The translation of the foreign language provisional application has been received. 15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal I	y (PTO-413) Paper No(s) Patent Application (PTO-152)				

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DETAILED ACTION

Election/Restrictions

1. During a telephone conversation with J. Warren Whitsel on September 27, 2001, a provisional election was made with traverse to prosecute claims 1-11. However, upon reconsideration the examiner is of the opinion that the restriction is improper. Therefore, the restriction is withdrawn and all claims in the application, 1-23, are treated in this office action.

Claim Rejections - 35 USC § 112

- The following is a quotation of the second paragraph of 35 U.S.C. 112:
 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 3. Claims 19-23 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. It is unclear what the exactly the applicant is claiming. Replacement of the word "and" with the word "or" in the phrase "... process is one of chemical vapor deposition process and physical vapor deposition process" would remedy this problem. The claim was treated with this replacement.

Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

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The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) do not apply to the examination of this application as the application being examined was not (1) filed on or after November 29, 2000, or (2) voluntarily published under 35 U.S.C. 122(b). Therefore, this application is examined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

- 5. Claims 1-2, 5-6, 7-9 and 18-19 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent No. 6,139,642 to Shimahara et al.
- 6. With respect to claims 1-2, 5-6 and 9, Shimahara et al. disclose a chemical vapor deposition apparatus in Figure 1 for forming a film on a wafer in a semiconductor process comprising: an inner part (2a) and an outer part (1a) with a gas-feeding pipe (241) mounted in between the inner and outer parts, so that an gas inlet and gas outlet are formed between the inner and outer parts. The feeding gas pipe contains a plurality of holes on the side near the outer part and is oriented in a direction so that gas flow is directed toward the outer part (Figure 10; column 21, rows 41-43). Shimahara et al. teaches that the holes may be gradient (column 6, row 65 column 7, row 4).
- 7. With respect to claim 8, the gas feeding pipe pf Shimahara et al. has a length that is shorter that two-thirds of the inner part (Figure 10), and is self-evidently less than 70 cm.
- 8. With respect to claims 18-19, Shimahara et al. disclose a method for feeding a gas into the above film forming apparatus comprising feeding the gas into a space between the inner and outer part and leading the gas into the inner part along a path between the two parts (claim 20).

Claim Rejections - 35 USC § 103

9. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 10. Claims 3-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shimahara et al. as applied to claims 1-2, 5-6, 7-9 and 18-19 above, and further in view of U.S. Patent No. 6,074,486 to Yang et al.
- 11. Shimahara et al. disclose an apparatus for forming a film on a wafer comprising an inner part, outer part and gas feeding pipe.

Unlike the claimed invention, the construction material for the inner part, outer part and gas feeding device are not disclosed in Shimahara et al.

Yang et al. disclose a similar apparatus for forming a film on a wafer, where they teach the use of quartz and SiC as appropriate construction materials for the inner part, outer part and gas feeding device due to their inherent properties as ceramic materials (column 6, rows 4-5 & 51-53).

It would have been obvious to one skilled in the art and therefore familiar with the properties of quartz and SiC to modify the teachings of Shimahara et al., by including them as construction materials for the inner part, outer part and gas feeding tube of the claimed invention.

- 12. Claims 10-12, 14-17 and 20-22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shimahara et al. as applied to claim 1-2, 5-6, 7-9 and 18-19 above, and further in view of U.S. Patent No. Re. 36,328 to Miyashita et al.
- 13. Shimahara et al. disclose an apparatus for forming a film on a wafer comprising an inner part, outer part and gas-feeding pipe. The apparatus further comprises a flow controller (247), a heating device (212) and a pumping device (2D).

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Unlik th claimed invention, Shimahara et al. do not disclose the optimum process conditions for using the apparatus.

Miyashita et al. disclose a similar apparatus for forming a silicon nitride film (column 2, rows 27-30) on a wafer using nitrogen as the purge gas (column 3, rows 57-59), where additional details on optimum process conditions are disclosed. The apparatus of Miyashita et al. is capable of the claimed flow rates, process temperatures and process pressure (column 4, rows 47-49). Additionally, the invention of Miyashita et al. includes the claimed temperature differential between the feeding gas and inner part. The gases of the invention are fed at a low temperature, approximately 30-180°C, in the lower portion of the apparatus and are then processed at a higher temperature within the inner part, approximately 780°C (Figure 3, column 4, rows 7-13 & 47).

- 14. It would have been obvious to one skilled in the art to modify the invention of Shimahara to include the optimized process conditions disclosed in Miyashita et al. to provide a semiconductor manufacturing apparatus that can produce silicon nitride films having identical thickness and qualities.
- 15. With respect to claim 13, the exact length of the gas feed tube would be determined by the relative size of the overall apparatus. The courts have ruled that where the only difference between the prior art and the claims is a recitation of relative dimensions of the claimed device and a device having the claimed relative dimensions would not perform differently than the prior art device, the claimed device is not patentably distinct from the prior art device. In Gardner v. TEC Systems, Inc., 725 F.2d 1338, 220 USPQ 777 (Fed. Cir 1984), cert. Denied, 469 U.S. 830, 225 USPQ 232 (1984).

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Allowable Subject Matter

16. Claim 23 is objected to as being dependent upon a rejected base claim, but would be

allowable if rewritten in independent form including all of the limitations of the base claim and

any intervening claims.

Conclusion

17. The prior art made of record and not relied upon is considered pertinent to applicant's

disclosure.

Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Karla Moore whose telephone number is 703.305.3142. The examiner

can normally be reached on Monday-Friday, 8:30am-5:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Gregory Mills can be reached on 703.308.1633. The fax phone numbers for the

organization where this application or proceeding is assigned are 703.872.9310 for regular

communications and 703.872.9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is 703.308.0661.

km

January 28, 2002

GREGORY MILLS

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